



Patent
Attorney's Docket No. 015290-457

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Patent Application of)
Jerome S. HUBACEK et al.) Group Art Unit: 1763 #18
Application No.: 09/749,916) Examiner: L. Alejandro Mulero
Filed: December 29, 2000) Confirmation No.: 6834
For: ELECTRODE FOR PLASMA)
PROCESSES AND METHOD FOR)
MANUFACTURE AND USE)
THEREOF)

3/20/03
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REQUEST FOR RECONSIDERATION

Assistant Commissioner for Patents
Washington, D.C. 20231

Sir:

In response to the Office Action dated December 17, 2002, Applicants submit the following remarks.

REMARKS

Claims 1, 3-10, 21, 23, 25 and 27-30 are pending. Reconsideration of the December 17, 2002, Official Action is respectfully requested.

Claims 1, 3-10, 21-23 and 27-29 were rejected in the Official Action under 35 U.S.C. § 112, first paragraph. The reasons for the rejection are stated at page 2 of the Official Action. The rejection is respectfully traversed for the following reasons.

Claim 1 recites "the electrode having a thickness of about 0.3 inch to 0.5 inch". As was explained in the Amendment After Final Rejection filed on October 28, 2002, support for this recitation is provided at page 13, lines 15-21 of the specification. Namely, the specification discloses that one approach for enhancing reduction of the center-to-edge

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